

Control of hot carrier thermalization in type-II quantum wells: a route to practical hot carrier solar cells



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- Introduction: Hot Carrier Solar Cells
- InAs/AIAs_xSb_{1-x} QWs and Optical Properties
- Hot Carrier Temperatures and Thermalization Coefficient
- Dynamics of Hot Carriers
- DFT Calculations and Raman Spectroscopy
- Electrical Characterization: Hot Carrier p-i-n diode



Introduction: Hot Carrier Solar cell







Photovoltaics Materials & Device Group, University of Oklahoma: http://www.nhn.ou.edu/~sellers/group/index.html



Introduction: Hot Carrier Solar cell





https://www.esa.int/spaceinimages/Images/2017/12/Solar_spectrum



 Maximum Theoretical Conversion Efficiency:
 33% No-Concentration (1 sun) (Shockley-Queisser Limit)



Introduction: Hot Carrier Solar cell





Maximum Theoretical Conversion
 Efficiency:
 68% No-Concentration (1 sun)



Determination of carrier temperature Linear fit



$$I_{PL}(E) = \frac{A(E) (E)^2}{4\pi^2 h^3 c^2} \left[exp\left(\frac{E - \Delta \mu}{k_B T}\right) - 1 \right]^{-1}$$

- Lasher & Stern, Phys. Rev. 133, A553 (1964)
- De Vos & Pauwels, Appl. Phys. 25, 119 (1981)
- P Wurfel, J. Phys. C: Solid State Phys. 15 3967 (1982)



Related Research:

Generalized Planck's law

- A. Le Bris, L. Lombez, J. F. Guillemoles, *Energy & Environmental Science*, *5*(3), 6225-6232 (2012).
- G. Conibeer, N. J. Ekins-Daukes, J. F. Guillemoles, D. Kőnig, M. Green, Solar Energy Materials and Solar Cells, 93(6-7), 713-719 (2009).
- L. C. Hirst, M. Sugiyama, N. J. Ekins-Daukes, *IEEE Journal of Photovoltaics*, 4(1), 244-252 (2014).



Determination of carrier temperature Linear fit

Generalized Planck's law



$$I_{PL}(E) = \frac{A(E) (E)^2}{4\pi^2 h^3 c^2} \left[exp\left(\frac{E - \Delta \mu}{k_B T}\right) - 1 \right]^{-1}$$

• Lasher & Stern, *Phys. Rev.* **133**, A553 (1964)

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Type-II InAs/AlAs_{0.16}Sb_{0.84} quantum well structure





- "Deep" QW in the conduction band
- Quasi-type | structure
- Low quantum confinement in valence band
- Potential of creating resonant tunneling through a superlattice structure
- J. Tang, H. Esmaielpour et al. Appl. Phys. Lett. 106, 061902 (2015)





Analysis of Hot Carriers and their temperature (T_{eh})





- Below 90 K, phonon mediated thermalization of hot carriers due to localized states at the interface is dominant.
- Above 90 K, radiative recombination of spatially separated photogenerated charges in type-II band alignment is the dominant mechanism which creates robust hot carrier effect at elevated temperatures.
 - J. Tang, H. Esmaielpour et al. Appl. Phys. Lett. 106, 061902 (2015)



Thermalization coefficient in InAs/AlAsSb QWs



$$P_{abs} = P_{th} = Q(T_{eh} - T) \exp\left(-\frac{hv_{LO}}{k_B T_{eh}}\right)$$

Q: Thermalization coefficient

Le Bris, A., *et al.* Energy & Environmental Science 5.3 (2012): 6225-6232.



H. Esmaielpour, I. R. Sellers, et al. Prog. Photovolt: Res. Appl., 24: 591–599 (2016).



Time Domain THz Spectroscopy: AC Photoconductivity





Processed Sample for Ultra-fast Transient Absorption Spectroscopy







H. Esmaielpour, I. R. Sellers, et al. Scientific Reports (under review).



Time Domain THz Spectroscopy: AC Photoconductivity





E: THz Electric Fields A_i : Normalized Amplitude τ_i : Decay Time

WestVirginia н. Р. Ріуаthilaka, А. D. Bristow University

H. Esmaielpour, I. R. Sellers, et al. Scientific Reports (under review).

V. R. Whiteside, H. Esmaielpour, I. R. Sellers, et al. Semiconductor Science and Technology (under review).



Phononic Properties of InAs/AlAsSb QW Structure DFT Calculations





- Large optical phonon band gap for AISb sample due to a large difference between cation and anion mass.
- ★ Large difference between optic and acoustic phonon energy for AlSb ($\hbar\omega LO/\hbar\omega LA \sim 1.9$) (see tan shaded region) and small difference between optic and acoustic phonon energy ($\hbar\omega LO/\hbar\omega LA \sim 1.1$) for InAs (see green shaded region)





B. Wang

H. Esmaielpour, I. R. Sellers, et al. Scientific Reports (under review).



Phononic Properties of InAs/AlAsSb QW Structure

Raman Spectroscopy

	InAs 50 nm Cap
	AIAs _{.16} Sb _{.84} 10 nm
201	InAs 2.4 nm
<u> </u>	AIAs _{.16} Sb _{.84} 10 nm
	InAs 2000 nm
	GaAs Substrate





E. Adcock-Smith, K. P. Roberts

H. Esmaielpour, I. R. Sellers, et al. Scientific Reports (under review).



Phononic Properties of InAs/AlAsSb QW Structure

Raman Spectroscopy

	InAs 50 nm Cap
30x-[AIAs _{.16} Sb _{.84} 10 nm
	InAs 2.4 nm
	AIAs _{.16} Sb _{.84} 10 nm
	InAs 2000 nm
	GaAs Substrate



- Limited contribution of phonon process in the barriers (AlAsSb) in carrier thermalization.
- Strong confinement of hot electron-phonon process within the QWs.
- Up-conversion of LA phonons to LO phonons and re-heating and stabilizing hot electron distribution within the InAs QW.
- H. Esmaielpour, I. R. Sellers, *et al.* Scientific Reports (under review).





Electrical characterization: Hot carrier p-i-n diode

I-V measurements as a function of barrier thickness





Related Research:

• L. C. Hirst, R. J. Walters, M. F. Führer, N. J. Ekins-Daukes, *Applied Physics Letters*, *104*(23), 231115, (2014).





Electrical characterization: Hot carrier p-i-n diode I-V measurements as a function of barrier thickness



✤ At reverse bias where there is a large band bending, generated electrons can tunnel through the barrier material into the n-doped region.



Voltage (V)

✤ At forward bias, confinement of hot carriers within the QW was observed due to small band bending of the QW structure.



Electrical characterization: Hot carrier p-i-n diode I-V measurements as a function of barrier thickness



Smaller carrier confinement within the QW is observed for the p-i-n device with a thinner barrier material.



2 nm barrier p-i-n diode

10 nm barrier p-i-n diode

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Electrical characterization: Hot carrier p-i-n diode

• Power dependence

- By increasing the barrier thickness, less amount of current can escape from the confinement of the QW.
- ✤ As power increases, more hot electrons can escape from the QW.

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Summary

- InAs/Al_xAs_{1-x}Sb quantum wells offer potential as active absorber in hot carrier solar cells.
- Thermalization factor analysis appears unsuitable for the proposed mechanism at higher temperatures.
- Evidence of state filling in the valence band has been observed.
- Carrier temperatures and chemical potentials for generated electrons and holes have been found using the non-equilibrium generalized Planck's law.
- Tera-hertz time domain spectroscopy (TDS) has been done using a processed sample made of only the InAs MQWs.
- Hot carrier p-i-n diodes have shown the existence of hot carriers confined within the InAs
 MQWs.
 Acknowledgments

